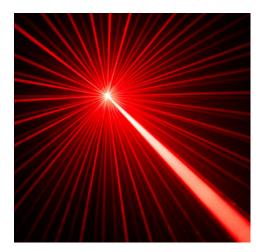
Develop on Press Thermal Negative Offset Plate



NO CHEMISTRY - NO PROCESSOR

4 EASY STEPS TO PRODUCTION



EXPOSE

Fast 120 mj/cm2 Exposure Range: 110 to 145mj/cm2

MOUNT

White Light Handling Visible Image for Plate ID





DAMPEN

Engage Dampening Rollers for Several Revolutions





LEARN MORE AT www.n1nsolutions.com/eco-pro-dop